

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.	:	10/598,471	Confirmation No. 5838
Applicant	:	Yuichiro Shindo et al.	
371 Filed	:	August 31, 2006	
Art Unit	:	1793	
Examiner	:	Vanessa T. Velasquez	
Customer No.	:	00270	
Title	:	HIGH-PURITY Ru POWDER, SPUTTERING TARGET OBTAINED BY SINTERING THE SAME, THIN FILM OBTAINED BY SPUTTERING THE TARGET AND PROCESS FOR PRODUCING HIGH-PURITY Ru POWDER	

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT**

Sir:

This is an Amendment timely filed in response to a non-final Office Action dated January 5, 2009. Kindly amend the application as set forth below.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.